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In The Claims

Please enter new claims 40 and 41 as follows.

1. (Previously presented) A material comprising Si, C, O and H, said composition having a non-polymeric, covalently bonded structure comprising Si-C, Si-H, Si-O and C-H bonds and a dielectric constant of not more than 3.6.

2. - 39. (Cancelled)

- 40. (NEW) A material comprising Si, C, O and H, said composition having a non-polymeric, covalently bonded structure comprising Si-C, Si-H, Si-O and C-H bonds and a dielectric constant of not more than 3.6, said composition further comprises between about 5 and about 40 atomic percent of Si; between about 5 and about 45 atomic percent of C; between 0 and about 50 atomic percent of O; and between about 10 and about 55 atomic percent of H, said composition further comprises at least one element selected from the group consisting of F, N, and Ge.
- 41. (NEW) A material composition comprising elements of Si, C and H, said composition having a non-polymeric covalently

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bonded ring network comprising Si-C, Si-H and C-H bonds and a dielectric constant of not more than 3.6.

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The Commissioner is hereby authorized to charge the fee required for these additional claims and any other fee as required to Deposit Account No. 50-0510.

Respectfully submitted,

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